

EXPRESSION OF CONCERN

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Expression of concern: *In situ* growth of N-doped carbon nanotubes from the products of graphitic carbon nitride etching by nickel nanoparticles

Mariusz Pietrowski, *^a Emilia Alwin, Michał Zieliński, Sabine Szunerits, ^b Agata Suchora ^a and Robert Wojcieszak *^{cd}Expression of concern for 'In situ growth of N-doped carbon nanotubes from the products of graphitic carbon nitride etching by nickel nanoparticles' by Mariusz Pietrowski *et al.*, *Nanoscale Adv.*, 2024, **6**, 1720–1726, <https://doi.org/10.1039/D3NA00983A>.

The Royal Society of Chemistry is publishing this expression of concern in order to alert readers that concerns have been raised regarding the reliability of the data. The Royal Society of Chemistry has asked the University of Lille to investigate this matter. An expression of concern will continue to be associated with the article until we receive conclusive evidence regarding the reliability of the reported data.

Dr Jeremy Allen
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Executive Editor, *Nanoscale Advances*

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